

Dante Ferreira Franceschini

List of Publications by Year in descending order

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49
papers

1,556
citations

331259

21
h-index

301761

39
g-index

49
all docs

49
docs citations

49
times ranked

1003
citing authors

#	ARTICLE	IF	CITATIONS
1	Nitrogen modification of hydrogenated amorphous carbon films. <i>Journal of Applied Physics</i> , 1997, 81, 2626-2634.	1.1	333
2	Internal stress reduction by nitrogen incorporation in hard amorphous carbon thin films. <i>Applied Physics Letters</i> , 1992, 60, 3229-3231.	1.5	218
3	Structural and mechanical characterization of fluorinated amorphous-carbon films deposited by plasma decomposition of CF_4 - CH_4 gas mixtures. <i>Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films</i> , 2000, 18, 2230.	0.9	77
4	Structure and mechanical properties of hard amorphous carbon-nitrogen films obtained by plasma decomposition of methane-ammonia mixtures. <i>Thin Solid Films</i> , 1997, 293, 236-243.	0.8	75
5	Magnetic properties of $Ce(Fe_{1-x}Al_x)_2$ for $x \approx 0.20$. <i>Journal of Magnetism and Magnetic Materials</i> , 1985, 51, 280-290.	1.0	67
6	Atomic force microscopy of amorphous hydrogenated carbon-nitrogen films deposited by radio-frequency plasma decomposition of methane-ammonia gas mixtures. <i>Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films</i> , 1996, 14, 2351-2355.	0.9	56
7	Nitrogenated amorphous carbon as a semiconductor. <i>Diamond and Related Materials</i> , 1996, 5, 401-404.	1.8	50
8	Film growth and relationship between microstructure and mechanical properties of a-C:H:F films deposited by PECVD. <i>Diamond and Related Materials</i> , 2001, 10, 125-131.	1.8	49
9	Influence of precursor gases on the structure of plasma deposited amorphous hydrogenated carbon-nitrogen films. <i>Applied Physics Letters</i> , 1996, 68, 2645-2647.	1.5	45
10	Hard amorphous hydrogenated carbon-nitrogen films obtained by PECVD in methane-ammonia atmospheres. <i>Diamond and Related Materials</i> , 1996, 5, 471-474.	1.8	39
11	Structural modifications in a-C:H films doped and implanted with nitrogen. <i>Diamond and Related Materials</i> , 1994, 3, 88-93.	1.8	36
12	Carbon nitride thin films prepared by reactive sputtering: Elemental composition and structural characterization. <i>Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films</i> , 1997, 15, 1970-1975.	0.9	35
13	Polyaniline nanofibers-graphene oxide nanoplatelets composite thin film electrodes for electrochemical capacitors. <i>RSC Advances</i> , 2014, 4, 34168-34178.	1.7	33
14	Growth kinetics and relationship between structure and mechanical properties of a-C(N):H films deposited in acetylene-nitrogen atmospheres. <i>Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films</i> , 1999, 17, 545-551.	0.9	32
15	RBS, ERDA and NR analyses of hard amorphous nitrogen-incorporated carbon films. <i>Nuclear Instruments & Methods in Physics Research B</i> , 1994, 85, 268-271.	0.6	27
16	Tuning the morphology of manganese oxide nanostructures for obtaining both high gravimetric and volumetric capacitance. <i>Materials Advances</i> , 2020, 1, 2433-2442.	2.6	27
17	Amorphous hydrogenated carbon nitride films obtained by plasma-enhanced chemical vapour deposition. <i>Surface and Coatings Technology</i> , 1995, 74-75, 382-386.	2.2	24
18	Biogenic approaches using citrus extracts for the synthesis of metal nanoparticles: the role of flavonoids in gold reduction and stabilization. <i>New Journal of Chemistry</i> , 2016, 40, 1420-1429.	1.4	24

#	ARTICLE	IF	CITATIONS
19	Hard a-C(N):H films obtained from plasma decomposition of methylamine-containing mixtures. <i>Diamond and Related Materials</i> , 1997, 6, 631-634.	1.8	22
20	Fluorine incorporation into amorphous hydrogenated carbon films deposited by plasma-enhanced chemical vapor deposition: structural modifications investigated by X-ray photoelectron spectrometry and Raman spectroscopy. <i>Diamond and Related Materials</i> , 2001, 10, 910-914.	1.8	22
21	Er:SrF ₂ luminescent powders prepared by combustion synthesis. <i>Materials Chemistry and Physics</i> , 2012, 135, 317-321.	2.0	21
22	Structure and properties of a-C:H films deposited onto polymeric substrates. <i>Diamond and Related Materials</i> , 1997, 6, 551-554.	1.8	18
23	Support effect on carbon nanotube growth by methane chemical vapor deposition on cobalt catalysts. <i>Journal of the Brazilian Chemical Society</i> , 2012, 23, 868-879.	0.6	18
24	Two species model for deposition and erosion of carbon-nitrogen films. <i>Applied Physics Letters</i> , 1999, 74, 209-211.	1.5	17
25	Effects of postdeposition heat treatment on the structural and magnetic properties of CoFe ₂ O ₄ nanoparticles produced by pulsed laser deposition. <i>Journal of Applied Physics</i> , 2017, 122, .	1.1	17
26	Manganese oxide nanofoam prepared by pulsed laser deposition for high performance supercapacitor electrodes. <i>Materials Chemistry and Physics</i> , 2020, 242, 122459.	2.0	17
27	Characterization of hard amorphous carbon films implanted with nitrogen ions. <i>Nuclear Instruments & Methods in Physics Research B</i> , 1993, 80-81, 1464-1467.	0.6	14
28	Superconductivity in Bi/Ni bilayer system: Clear role of superconducting phases found at Bi/Ni interface. <i>Physical Review Materials</i> , 2018, 2, .	0.9	14
29	Nitrogen Incorporation into Hard Amorphous Carbon Films Obtained by RF Plasma Decomposition of CH ₄ -N ₂ Gas Mixtures. <i>Physica Status Solidi (B): Basic Research</i> , 1995, 192, 493-502.	0.7	13
30	Statistical models for carbon-nitrogen film growth. <i>Physical Review E</i> , 2000, 61, 3417-3425.	0.8	12
31	Deposition of hard amorphous hydrogenated carbon films by radiofrequency parallel-plate hollow-cathode plasmas. <i>Diamond and Related Materials</i> , 2007, 16, 616-622.	1.8	12
32	Plasma-deposited a-C(N): H films. <i>Brazilian Journal of Physics</i> , 2000, 30, 517-526.	0.7	11
33	Nanoporosity in plasma deposited amorphous carbon films investigated by small-angle X-ray scattering. <i>Diamond and Related Materials</i> , 2002, 11, 1946-1951.	1.8	11
34	Magnetic behaviour of the intermetallic compound Ce(Fe _{0.8} Al _{0.2}) ₂ . <i>Journal of Physics F: Metal Physics</i> , 1982, 12, 3083-3088.	1.6	10
35	Magnetic and electrical properties of iron-rich Ce(Fe _{1-x} Al _x) ₂ intermetallics: some remarks. <i>Journal of Magnetism and Magnetic Materials</i> , 1986, 62, 47-52.	1.0	8
36	In-depth modifications of implanted amorphous carbon films. <i>Applied Physics A: Solids and Surfaces</i> , 1994, 59, 667-672.	1.4	8

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37	Study of nitrogen implanted amorphous hydrogenated carbon thin films by variable-energy positron annihilation spectroscopy. <i>Journal of Applied Physics</i> , 1997, 81, 2451-2453.	1.1	7
38	Nickel nanoparticles supported by commercial carbon paper as a catalyst for urea electro-oxidation. <i>Materials for Renewable and Sustainable Energy</i> , 2020, 9, 1.	1.5	7
39	Amorphous carbon films deposited by direct current-magnetron sputtering: Void distribution investigated by gas effusion and small angle x-ray scattering experiments. <i>Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films</i> , 2000, 18, 2344.	0.9	6
40	Nanostructured europium oxide thin films deposited by pulsed laser ablation of a metallic target in a He buffer atmosphere. <i>Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films</i> , 2010, 28, 1092-1098.	0.9	5
41	Surface modifications in diamond-like carbon films submitted to low-energy nitrogen ion bombardment. <i>Nuclear Instruments & Methods in Physics Research B</i> , 2001, 175-177, 699-704.	0.6	4
42	Comparison of the properties of a-C:H films deposited from methane and heptane precursors: study of the mechanical, chemical and structural properties. <i>Thin Solid Films</i> , 2020, 695, 137733.	0.8	4
43	Cobalt Catalyst Characterization for Methane Decomposition and Carbon Nanotube Growth. <i>Journal of the Brazilian Chemical Society</i> , 2014, , .	0.6	3
44	Structural Disorder in Hard Amorphous Carbon Films Implanted with Nitrogen Ions. <i>Materials Research Society Symposia Proceedings</i> , 1995, 396, 227.	0.1	2
45	Growth, Structure, and Properties of Plasma-Deposited Amorphous Hydrogenated Carbon-Nitrogen Films. <i>Thin Films and Nanostructures</i> , 2002, , 217-276.	0.1	2
46	Structural and optical characterization of fluorinated hydrogenated silicon carbide films deposited by pulsed glow discharge. <i>Surface and Coatings Technology</i> , 2006, 200, 6079-6082.	2.2	2
47	Growth, structure, and properties of plasma-deposited amorphous hydrogenated Carbon-Nitrogen films. , 2002, , 649-676.		1
48	sp-hybridized carbon atoms formed by low-energy collisions in carbon nanofoams produced by pulsed laser deposition. <i>Materials Letters</i> , 2022, 314, 131886.	1.3	1
49	Voids Investigation of Amorphous Carbon Films Deposited by DC-Magnetron Sputtering: A Small Angle x-ray Scattering and Gas Thermal Effusion Study. <i>Materials Research Society Symposia Proceedings</i> , 1999, 593, 383.	0.1	0